

LISTING OF THE CLAIMS

1. (Currently Amended) A magnetic random access memory cell comprising:

a first magnetic storage element having a first sense layer and a first pinned layer;

a second magnetic storage element having a second sense layer and a second pinned layer, said first and second sense layers being mutually electrically coupled through first and second read conductors, said first and second read conductors having respective longitudinal axes, said first and second pinned layers being electrically coupled to respective first and second read/write conductors, said first and second read/write conductors having at least localized longitudinal axes in respective vicinities of said first and second magnetic storage elements, said at least localized longitudinal axes of said first read/write conductor being oriented substantially parallel to said longitudinal axis of said first read conductor;

a switching device ~~having a first controlled terminal~~ coupled to said mutually coupled pinned layers through said first and second read conductors, ~~a second controlled terminal coupled to a source of~~ and configured to couple said mutually coupled pinned layers to a conductor for receiving a substantially constant potential, ~~and a control terminal adapted to receive a control signal.~~

2. (Currently Amended) A magnetic random access memory cell as defined in claim 1 wherein said ~~source of~~ substantially constant potential comprises a ~~source of~~ ground potential.

3. (Currently Amended) A magnetic random access memory cell as defined in claim 1 wherein said first magnetic storage element and said second magnetic storage element are disposed above said switching device in a first direction, and wherein said switching device is disposed ~~beside a further~~ adjacent to a second switching device of a ~~further~~ second magnetic random access memory cell ~~in a second direction~~.

4. (Currently Amended) A memory device comprising:

a plurality of read/write conductors ~~pairs~~ respectively paired with a plurality of read conductors, said respectively paired read/write and read conductors having substantially parallel longitudinal axes;

at least one memory cell electrically coupled ~~between each of~~ to each said respectively paired read/write conductor ~~pairs~~ and read conductor, said at least one memory cell including a ~~controllable~~ transistor and ~~exactly~~ two resistive memory elements, said ~~exactly~~ two resistive memory elements being ~~coupled~~ electrically connected in series by respective said read conductors, said ~~exactly~~ two resistive memory elements being mutually coupled to said ~~controllable~~ transistor at a common node.

5. (Currently Amended) A memory device as defined in claim 4 wherein:

said ~~exactly~~ two resistive memory elements each include a pinned layer and a sense layer; and

wherein said sense layer of each said resistive memory element is electrically coupled through said ~~controllable~~ transistor to a ~~source of~~ conductor for receiving a substantially constant electrical potential.

6. (Currently Amended) A memory device as in claim 5 wherein said ~~source~~ of substantially constant electrical potential is a ~~source of~~ ground potential.

7. (Currently Amended) A memory device as defined in claim 4 wherein said ~~controllable~~ transistor comprises:

two transistors having a common drain connection and respective gate terminals, said gate terminals mutually coupled to one another.

8. (Currently Amended) A memory device as defined in claim 4 wherein:

said first and second resistive memory elements are disposed in layered spaced relation to one another above said ~~controllable~~ transistor.

9. (Currently Amended) A memory device as defined in claim 4 further comprising:

a word line conductor electrically coupled to a gate of said ~~controllable~~ transistor.

10. (Original) A memory integrated circuit comprising:

a first two-dimensional array of resistive memory elements disposed in substantially parallel spaced relation between a second two-dimensional array of resistive memory elements and a third two-dimensional array of isolation devices, each

isolation device of said third two-dimensional array being coupled to at least one resistive memory element of said first two-dimensional array and at least another resistive memory element of said second two-dimensional array;

a first plurality of read/write conductors having respective longitudinal axes oriented in a first direction and coupled to said first two-dimensional array of resistive memory elements; and

a second plurality of read conductors having respective longitudinal axes also oriented in said first direction and also coupled to said first two-dimensional array of resistive memory elements.

11. (Original) A memory integrated circuit as defined in claim 10 wherein said first array of resistive memory elements comprises an array of MRAM memory elements.

12. (Currently Amended) A memory integrated circuit as defined in claim 10 wherein said first array of resistive memory elements comprises an array of ~~PCRAM~~ programmable conductive memory elements.

13. (Original) A memory integrated circuit as defined in claim 10 further comprising:

a sensing circuit, said sensing circuit adapted to sense a state of said resistive memory elements during a time interval when a respective isolation device is activated.

14. (Original) A memory integrated circuit comprising:

a plurality of memory cells, each cell including:

first and second resistive memory storage elements, said first and second resistive memory storage elements being electrically coupled to respective first and second memory sensing circuits, said first and second resistive memory storage elements being mutually coupled to a reference potential through a common dual transistor.

15. (Original) A memory integrated circuit as defined in claim 14 wherein said first and second resistive memory storage elements are disposed in spaced relation above said common dual transistor.

16. (Original) A memory integrated circuit as defined in claim 14 further comprising an address decoder electrically coupled to first and second gates of said dual transistor and adapted to activate said dual transistor in response to an address signal received at an address input of said address decoder.

17. (Currently Amended) A magnetic random access memory device comprising:

a semiconductor substrate having an upper surface;

a ~~controlled~~ transistor having a drain region ~~disposed on~~ supported by said semiconductor substrate;

a first magnetic random access memory storage element ~~disposed above~~ over said upper surface and above said drain region ~~in spaced relation thereto~~ and electrically coupled to said drain region through a first read conductor, said first read conductor having a first longitudinal axis;

a second magnetic random access memory storage element ~~disposed above~~ over said upper surface and above said first magnetic random access memory storage element ~~in spaced relation thereto~~ and electrically coupled to said first magnetic random access memory storage element and ~~electrically coupled to~~ said drain region through a second read conductor, said second read conductor having a second longitudinal axis; and

first and second read/write conductors having respective third and fourth longitudinal axes, said first longitudinal axis being disposed substantially parallel to said third longitudinal axis, said second longitudinal axis being disposed substantially parallel to said fourth longitudinal axis.

18. (Currently Amended) A PCRAM programmable conductive memory device comprising:

a semiconductor substrate having an upper surface;

a ~~controlled~~ transistor having a drain region ~~disposed on~~ supported by said semiconductor substrate;

a first PCRAM programmable conductive memory storage element disposed above said upper surface ~~and above said drain region in spaced relation thereto~~ and electrically coupled to said drain region ~~through~~ by a first read conductor, said first read conductor having a first longitudinal axis;

a second PCRAM programmable conductive memory storage element disposed ~~above said upper surface and~~ above said first PCRAM programmable conductive memory storage element ~~in spaced relation thereto~~ and electrically coupled

to said first ~~PCRAM~~ programmable conductive memory storage element and ~~electrically coupled to~~ said drain region through a second read conductor, said second read conductor having a second longitudinal axis; and

first and second read/write conductors having respective third and fourth longitudinal axes, said first longitudinal axis being disposed substantially parallel to said third longitudinal axis, and said second longitudinal axis being disposed substantially parallel to said fourth longitudinal axis.

19. (Currently Amended) A method of manufacturing a digital data storage device comprising:

forming a transistor layer, including a ~~first~~ plurality of ~~controlled~~ transistors, over a semiconductor substrate;

forming a first resistive memory storage layer over said transistor layer, said first resistive memory storage layer ~~including~~ comprising a ~~second~~ plurality of first resistive memory storage structures, each of said plurality of first resistive memory storage layer structures including a ~~third~~ plurality of respectively paired read conductors and a ~~fourth~~ plurality of read/write conductors, wherein said ~~third~~ plurality of read conductors and ~~said fourth~~ plurality of said read/write conductors ~~having a fifth plurality of each have a respective longitudinal axes axis and sixth plurality of longitudinal axes respectively,~~ said ~~fifth~~ plurality of longitudinal axes being of said respectively paired read conductors and read/write conductors are disposed in a substantially parallel relationship ~~to said sixth plurality of longitudinal axes;~~

forming a second magnetic memory storage layer over said first magnetic memory storage layer, including said second magnetic memory storage layer

comprising a ~~seventh~~ plurality of second magnetic memory storage structures, ~~over~~
~~said first magnetic memory storage layer; and~~

electrically coupling respective ones of said ~~first~~ plurality of ~~controlled~~
transistors, said ~~second~~ plurality of first magnetic memory storage structures, and said
~~seventh~~ plurality of second magnetic memory storage structures ~~to form a respective~~
~~plurality of multi-bit transistor isolated magnetic memory cells.~~

20. (Currently Amended) A method of manufacturing a digital data storage device as defined in claim 19 further comprising ~~[[:]]~~ forming a control circuit over said semiconductor substrate, said control circuit being ~~adapted to activate~~ configured for activating said ~~first~~ plurality of ~~controlled~~ transistors.

21. (Original) A processing system comprising:

a plurality of memory cells, each cell including:

first and second resistive memory storage elements, said first and second resistive memory storage elements being electrically coupled to respective first and second memory sensing circuits, said first and second resistive memory storage elements being mutually coupled to a reference potential through a wired-NOR FLASH memory style transistor.

22. (Currently Amended) A method of forming a memory device comprising:

forming a ~~first~~ plurality of NOR FLASH-memory style transistors disposed in ~~an first array above~~ over a semiconductor substrate;

forming an ~~second plurality~~ array of first resistive memory elements
~~disposed in a second array above said first array~~ over said transistors;

forming an array ~~third plurality~~ of second resistive memory elements
~~disposed in a third array above said second array~~ over said first resistive memory
elements; and

electrically coupling at least one second resistive memory element ~~of said~~
~~third plurality~~ to a respective first resistive memory element ~~of said second plurality~~
and to a respective ~~FLASH-memory style transistor of said first plurality~~.